



LECTURE 11

Introductory Lecture on Section C
-Semiconductors



Topics to be covered

- Continuity Equation

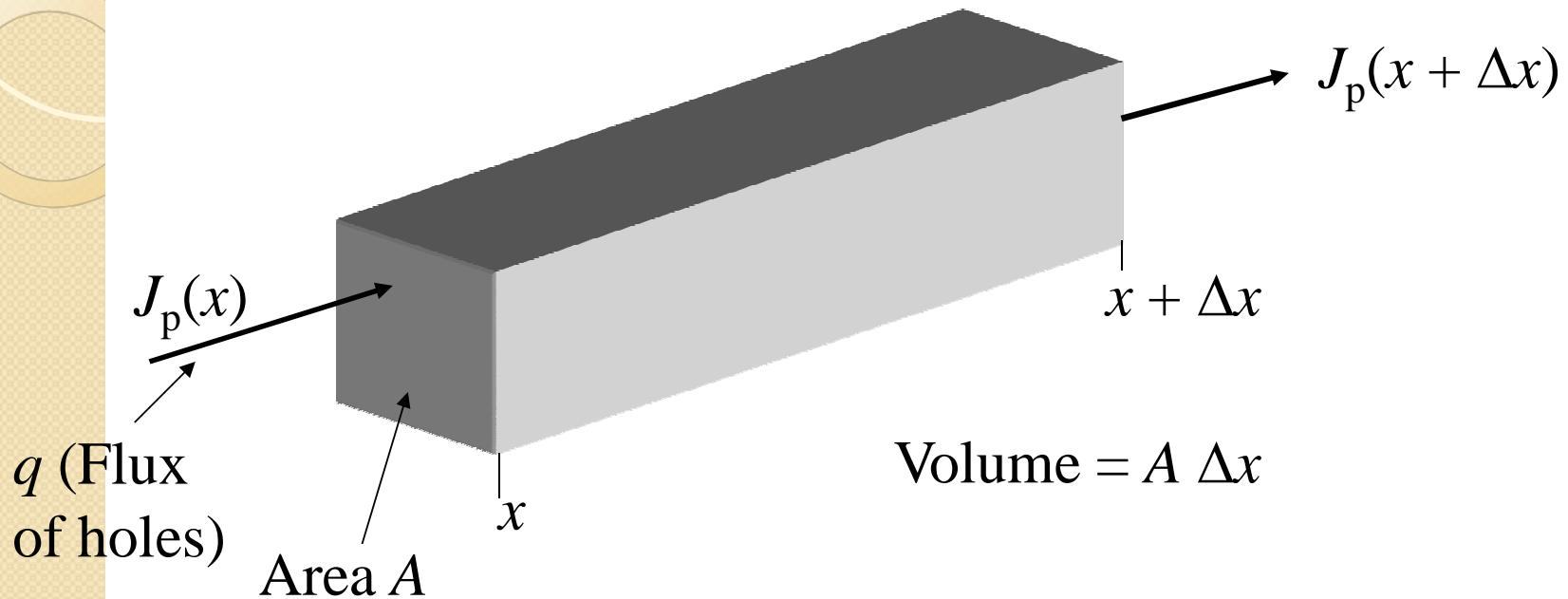
Continuity equation

- The continuity equation satisfies the condition that particles should be conserved! Electrons and holes cannot mysteriously appear or disappear at a given point, but must be transported to or created at the given point via some type of carrier action.
- Inside a given volume of a semiconductor,

$$\frac{\partial p}{\partial t} = \frac{\partial p}{\partial t} |_{\text{drift}} + \frac{\partial p}{\partial t} |_{\text{diffusion}} + \frac{\partial p}{\partial t} |_{\text{thermal}} + \frac{\partial p}{\partial t} |_{\text{others}} \\ \text{R-G} \quad \text{light etc.}$$

- There is a corresponding equation for electrons.

Continuity equation - consider 1D case



$$\begin{aligned} \frac{\partial p}{\partial t} A \Delta x &= \frac{A}{q} J_p(x) - \frac{A}{q} J_p(x + \Delta x) + A \Delta x \left(\frac{\partial p}{\partial t} \Big|_{\text{thermal R-G}} \right. \\ &\quad \left. \text{light etc.} \right) \\ &= \frac{A}{q} J_p(x) - \frac{A}{q} \left[J_p(x) + \frac{\partial J_p(x)}{\partial x} \Delta x \right] + A \Delta x \left(\frac{\partial p}{\partial t} \Big|_{\text{thermal R-G}} \right. \\ &\quad \left. \text{light etc.} \right) \end{aligned}$$

$$\frac{\partial p}{\partial t} A \Delta x = -\frac{A}{q} \frac{\partial J}{\partial x} \Delta x + A \Delta x \left(\frac{\partial p}{\partial t} \Big|_{\text{thermal R-G}}, \right. \\ \left. \text{light etc.} \right)$$

$$\frac{\partial p}{\partial t} = -\frac{1}{q} \frac{\partial J}{\partial x} + \frac{\partial p}{\partial t} \Big|_{\text{thermal R-G}}, \\ \text{light etc.}$$

$$\frac{\partial p}{\partial t} = -\frac{1}{q} \frac{\partial J}{\partial x} + \frac{\partial p}{\partial t} \Big|_{\text{thermal R-G}} + \frac{\partial p}{\partial t} \Big|_{\text{others light...}}$$

Continuity eqn. for holes

$$\frac{\partial n}{\partial t} = \frac{1}{q} \frac{\partial J}{\partial x} + \frac{\partial n}{\partial t} \Big|_{\text{thermal R-G}} + \frac{\partial n}{\partial t} \Big|_{\text{others light...}}$$

Continuity eqn. for electrons

These are general equations for one dimension, indicating that particles are conserved.

Minority carrier diffusion

Apply the continuity equations to minority carriers, with the following assumptions:

- Electric field $E = 0$ at the region of analysis
- Equilibrium minority carrier concentrations are not functions of position, i.e., $n_0 \neq n_0(x)$; $p_0 \neq p_0(x)$
- Low-level injection
- The dominant R-G mechanism is thermal R-G process
- The only external generation process is photo generation

Minority carrier diffusion equations

Consider electrons (for p-type) and make the following simplifications:

$$J_n = q\mu_n n E + qD_n \frac{\partial n}{\partial x} \approx qD_n \frac{\partial n}{\partial x}$$

$$\frac{\partial n}{\partial x} = \frac{\partial}{\partial x} (n_0 + \Delta n) = \frac{\partial \Delta n}{\partial x}$$

$$\frac{\partial n}{\partial t} \Big|_{\text{thermal } R-G} = -\frac{\Delta n}{\tau_n} \quad \text{and} \quad \frac{\partial n}{\partial t} \Big|_{\text{light etc.}} = G_L$$

$$\frac{\partial n}{\partial t} = \frac{\partial}{\partial t} (n_0 + \Delta n) = \frac{\partial \Delta n}{\partial t}$$

Minority carrier diffusion

eq

$$\frac{\partial \Delta n_p}{\partial t} = D_n \frac{\partial^2 \Delta n_p}{\partial x^2} - \frac{\Delta n_p}{\tau_n} + G_L$$

$$\frac{\partial \Delta p_n}{\partial t} = D_p \frac{\partial^2 \Delta p_n}{\partial x^2} - \frac{\Delta p_n}{\tau_p} + G_L$$

The subscripts refer to type of materials, either n-type or p-type.

Why are these called “diffusion equations”?

Why are these called “minority carrier” diffusion equations?

Example 1

Consider an n-type Si uniformly illuminated such that the excess carrier generation rate is G_L e-h pairs / (s cm³). Use MCDE to predict how excess carriers decay after the light is turned-off.

$t < 0$: uniform \rightarrow d/dx is zero; steady state \rightarrow $d/dt = 0$
So, applying to holes, $\Delta p(t < 0) = G_L \tau_p$

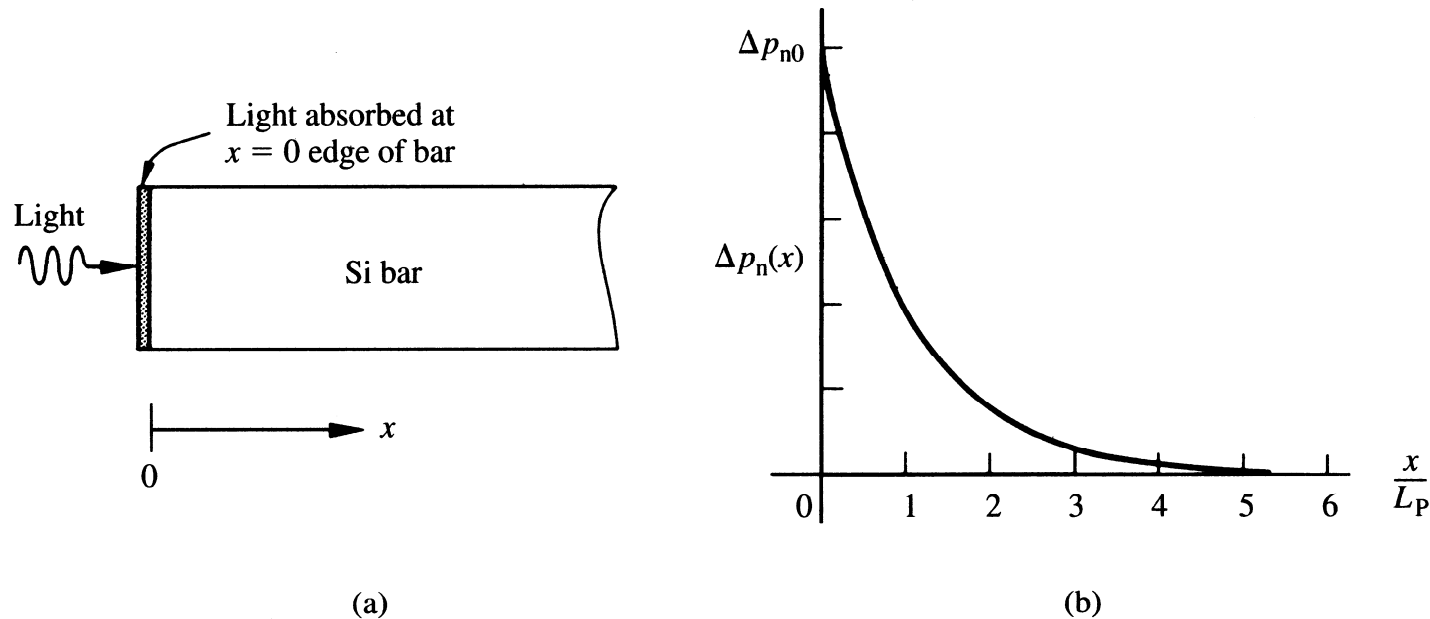
$t > 0$: $G_L = 0$; uniform \rightarrow $d/dx = 0$;

$$\frac{\partial \Delta p_n}{\partial t} = -\frac{\Delta p_n}{\tau_p} \quad \text{so,} \quad \Delta p_n = \Delta p_n(0) \exp(-t/\tau)$$

$$\Delta p(t > 0) = G_L \tau_p \exp\left(-\frac{t}{\tau_p}\right) \quad \text{since} \quad \Delta p(0) = G_L \tau_p$$

Example 2

Consider a uniformly doped Si with $N_D=10^{15} \text{ cm}^{-3}$ is illuminated such that $\Delta p_{n0}=10^{10} \text{ cm}^{-3}$ at $x=0$. No light penetrates inside Si. Determine $\Delta p_n(x)$. (see page 129 in text)



Solution is:

$$\Delta p_n(x) = \Delta p_{n0} \exp\left(-\frac{x}{L_p}\right) \quad \text{where} \quad L_p = \sqrt{D_p \tau_p}$$

Minority carrier diffusion length

In the previous example, the exponential falloff in the excess carrier concentration is characterized by a decay length, L_p , which appears often in semiconductor analysis.

$L_p = (D_p \tau_p)^{1/2}$ associated with minority carrier holes in n-type materials

$L_n = (D_n \tau_n)^{1/2}$ associated with minority carrier electrons in p-type materials

Physically L_n and L_p represent the average distance minority carriers can diffuse into a sea of majority carriers before being annihilated.

What are typical values for L_p and L_n ?